	Hits	Search Text	DBs
34	89	layer or spray\$4) same (photoresist or resist or polymide)) and ((photoresist or resist) same solvent same	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
35	0	polymide) same (viscos\$5 near16 (centipoises or poises or (Pascal near3 second) or Pasec\$3)) same	DERWENT; IBM_TDB
36		(photoresist or resist or polymide) same (viscos\$5 near16 (centipoises or poises or (Pascal	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
37	0	<pre>((coat\$4 or film or form\$4 or layer or spray\$4) same (photoresist or resist or polymide)) and ((photoresist or resist) same (solvent or solution) same volatil\$4 same</pre>	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
38	0	((coat\$4 or film or form\$4 or layer or spray\$4) same (photoresist or resist or polymide)) and ((photoresist or resist) same (coat\$4 or spray\$4)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
39	21	<pre>((photoresist or resist) same (coat\$4 or spray\$4) same ((relative near9 humidit\$3) near16 percent\$4))</pre>	US-PGPUB;
			USPAT; FPRS;
			EPO; JPO;
			DERWENT;
			IBM_TDB